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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/627,563	07/25/2003		Matthew Lewry	3001	5238
31424	7590	05/03/2005		EXAMINER	
BABCOCK	C IP LLC		CHEN, SHIH CHAO		
	24154 LAKESIDE DRIVE LAKE ZURICH, IL 60047				PAPER NUMBER
Di Med Zon	1011, 12	00017		2821	
				DATE MAILED: 05/03/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

				$A \cdot H$
		Application No.	Applicant(s)	
		10/627,563	LEWRY ET AL.	
	Office Action Summary	Examiner	Art Unit	
		Shih-Chao Chen	2821	
Period fo	The MAILING DATE of this communication ap or Reply	pears on the cover sheet w	ith the correspondence address	
THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period are to reply within the set or extended period for reply will, by statut reply received by the Office later than three months after the mailing departed term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a lip within the statutory minimum of thin will apply and will expire SIX (6) MON e. cause the application to become A	reply be timely filed ty (30) days will be considered timely. NTHS from the mailing date of this communic BANDONED (35 U.S.C. § 133).	ation.
Status				
1)⊠	Responsive to communication(s) filed on <u>07 M</u>	<u>March 2005</u> .		
2a)⊠	This action is FINAL . 2b) ☐ Thi	s action is non-final.		
3)[Since this application is in condition for allowa	•		s is
	closed in accordance with the practice under	Ex parte Quayle, 1935 C.E). 11, 453 O.G. 213.	
Disposit	ion of Claims			
4)⊠	Claim(s) 1-28 is/are pending in the application	٦.		
	4a) Of the above claim(s) is/are withdra	awn from consideration.		
5)[🖂	Claim(s) <u>1-27</u> is/are allowed.			
6)⊠	Claim(s) <u>28</u> is/are rejected.			
7)	Claim(s) is/are objected to.			
8)□	Claim(s) are subject to restriction and/o	or election requirement.		
Applicat	ion Papers		V	
•	The specification is objected to by the Examin			
10)⊠	The drawing(s) filed on <u>07 March 2005</u> is/are:			
	Applicant may not request that any objection to the			-440
	Replacement drawing sheet(s) including the correct			
11)[]	The oath or declaration is objected to by the E	xaminer. Note the attache	a Office Action or form P1O-152	۷.
Priority (under 35 U.S.C. § 119			
	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority document		§ 119(a)-(d) or (f).	
	2. Certified copies of the priority document		Application No.	
	3. Copies of the certified copies of the prior			<u>.</u>
	application from the International Burea			
* * *	See the attached detailed Office action for a lis		received.	
Attachmen		 □	O (DTO 442)	
	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948)		Summary (PTO-413) (s)/Mail Date	
3) 🔲 Infor	mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 or No(s)/Mail Date		Informal Patent Application (PTO-152)	
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DETAILED ACTION

Drawings

- 1. The formal drawings are required in response to this office action.
- 2. The drawings were received on March 7, 2005. These drawings are accepted by the Examiner.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claim 28 is rejected under 35 U.S.C. 102(b) as being anticipated by Knop et al. (U.S. Patent No. 6,107,973).

Regarding claim 28, Knop et al. teaches in figures 1-9 a reflector antenna, comprising: a dish shaped reflector [10] coupled to a feed assembly [11, 12, 13, 13a] proximate a vertex area of the reflector (See FIG. 2), the feed assembly having a waveguide [13] with a dielectric outer surface [12].

Allowable Subject Matter

- 5. Claims 1-27 are allowed.
- 6. The following is a statement of reasons for the indication of allowable subject matter:

The primary reason for the allowance of claims 1-8 is the inclusion of the limitation of a distal end of the waveguide flaring into a dielectric cone which couples

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with a sub reflector at a periphery of the sub reflector. It is this limitation found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

The primary reason for the allowance of claims 9-14 is the inclusion of the limitation of the waveguide flaring into a dielectric cone at a distal end. It is this limitation found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

The primary reason for the allowance of claims 15-19 is the inclusion of the limitation of the step of injection molding a waveguide having a dielectric cone at a distal end. It is this step found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

The primary reason for the allowance of claims 20-27 is the inclusion of the limitation of a dielectric cone extending from a waveguide radius at the distal end of the waveguide to a large sub reflector radius. It is this limitation found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

Response to Arguments

7. Applicant's arguments filed on March 7, 2005 have been fully considered but they are not persuasive.

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Applicant argues that the distal end of the waveguide of the cited reference does not, in fact, flare in to a dielectric cone. However, in claim 28 does not recite this limitation.

Conclusion

8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Correspondence

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shih-Chao Chen whose telephone number is (571) 272-1819. The examiner can normally be reached on Monday-Friday from 7 AM to 4:30 PM, First Fri. off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner supervisor, Don Wong can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Shik-I hao Chen Shih-Chao Chen Primary Examiner Art Unit 2821

SHIH-CHAO CHEN PRIMARY EXAMINER

SXC April 29, 2005